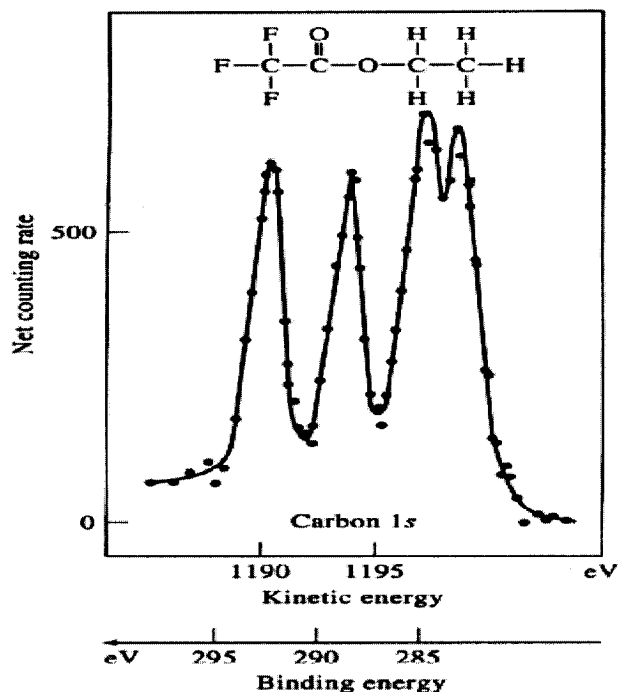


2008 Spring Analytical Chemistry Qualification Exam  
(answers can be in either Chinese or English)

1. Explain the ESCA spectrum of Trifluoroacetate shown on the right (10%)

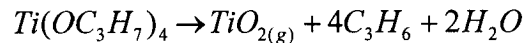


2. (a) Describe the mechanism of the production of MNN Auger electron;  
(b) Describe how it is possible to distinguish between the ESCA peaks from the Auger electron peaks in an ESCA spectrum. (20%)
3. (a) How does Scanning Electron Microscope work?  
(b) Describe principles of two major types of SEM detectors (20%)
4. The acid-base indicator HIn undergoes the following reaction in dilute aqueous solution:  $\text{HIn} \leftrightarrow \text{H}^+ + \text{In}^-$   
The following absorbance data were obtained for a  $5.00 \times 10^{-4}$  M solution of HIn in 0.1 M NaOH and 0.1 M HCl. Measurements were made at wavelengths of 485 nm and 625 nm with 1.00-cm cells.
- |            |                   |                   |
|------------|-------------------|-------------------|
| 0.1 M NaOH | $A_{485} = 0.075$ | $A_{625} = 0.904$ |
| 0.1 M HCl  | $A_{485} = 0.487$ | $A_{625} = 0.181$ |
- In the NaOH solution, essentially all of the indicator is present as  $\text{In}^-$ ; in the acidic solution, it is essentially all in the form of HIn.
- (a) Calculate molar absorptivities for  $\text{In}^-$  and HIn at 485 and 625 nm.  
(b) Calculate the acid dissociation constant for the indicator if a pH 5.00 buffer containing a small amount of the indicator exhibits an absorbance of 0.567 at 485 nm and 0.395 at 625 nm (1.00-cm cells).

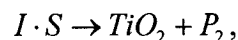
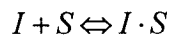
## 2008 Qualification examine of Chemical Reaction Engineering

### Undergraduate part

4. Titanium dioxide is a wide-band gap semiconductor that is showing promise as an insulating dielectric in VLSI capacitors and for use in solar cells. Thin films of  $TiO_2$  are to be prepared by chemical vapor deposition (CVD) from gaseous titanium tetraisopropoxide ( $TTIP$ ). The overall reaction is



The reaction mechanism in a CVD reactor is believed to be



where  $I$  is an active intermediate and  $P_1$  is one set of reaction products (e.g.,  $H_2O$ ,  $C_3H_6$ ) and  $P_2$  is another set. Assuming the homogeneous gas-phase reaction for  $TTIP$  is in equilibrium, derive a rate law for the deposition of  $TiO_2$ . The experimental results show that at  $200^\circ\text{C}$  the reaction is second order at low partial pressures of  $TTIP$  and zero order at high partial pressures, while at  $300^\circ\text{C}$  the reaction is second order in  $TTIP$  over the entire pressure range. Discuss these results in light of the rate law you derived. (20%)

5. The reaction  $A \rightarrow B$  is to be carried out isothermally in a continuous-flow reactor. Calculate both the CSTR and PFR reactor volumes necessary to consume 99% of A (i.e.,  $C_A = 0.01 C_{A0}$ ) when the entering molar flow rate is  $5 \text{ mol/h}$ , assuming the reaction rate  $-r_A$  is :

(a)  $-r_A = k$  with  $k = 0.05 \frac{\text{mol}}{\text{h} \cdot \text{dm}^3}$

(b)  $-r_A = kC_A$  with  $k = 0.0001 \text{ s}^{-1}$

(c)  $-r_A = kC_A^2$  with  $k = 3 \frac{\text{dm}^3}{\text{mol} \cdot \text{h}}$

The entering volumetric flow rate is  $10 \text{ dm}^3/\text{h}$ . (15%)

6. In order to study the photochemical decay of aqueous bromine in bright sunlight, a small quantity of liquid bromine was dissolved in water contained in a glass battery jar and placed in direct sunlight. The following data were obtained at 25°C :

<i>Time</i> (min)	10	20	30	40	50	60
ppm Br <sub>2</sub>	2.45	1.74	1.23	0.88	0.62	0.44

- (a) Determine whether the reaction rate is zero, first, or second order in bromine, and calculate the reaction rate constant in units of your choice.
- (b) Assuming identical exposure conditions, calculate the required hourly rate of injection of bromine (in pounds) into a sunlit body of water, 25000 gal in volume, in order to maintain a sterilizing level of bromine of 1.0 ppm.
- (c) What experimental conditions would you suggest if you were to obtain more data?
- (15%)